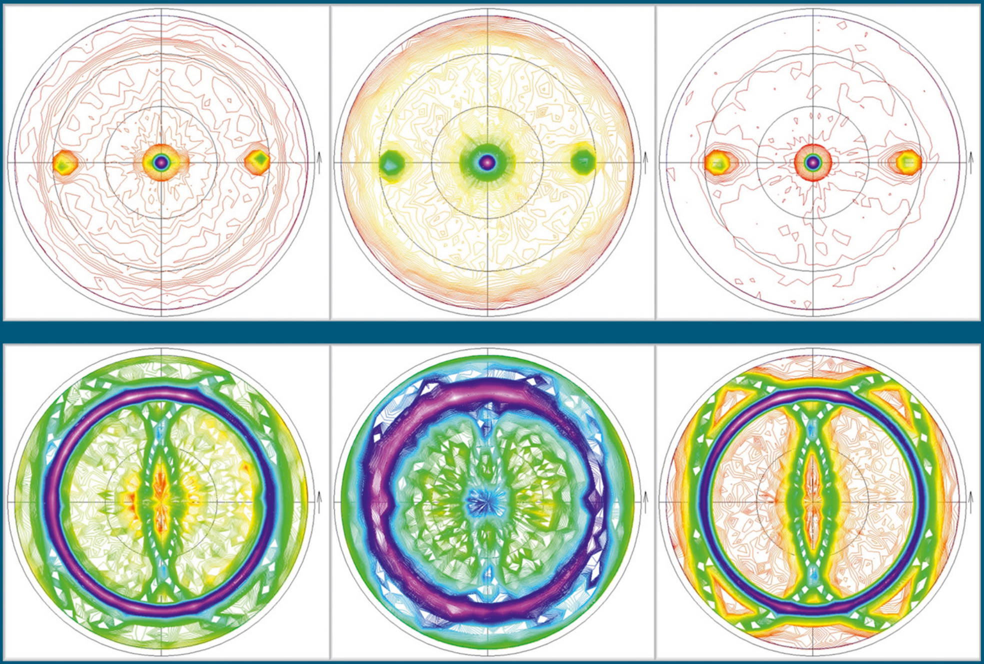
Conductivity and Structure of Sputtered ZnO:Al on Flat and Textured Substrates for Thin-Film Solar Cells

Nicolas Sommer



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